

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant :	SATO, et al.) Group Art Unit Unknown
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Int'l App. No. :	PCT/JP03/16266)
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Int'l Filing Date :	December 18, 2003)
)
For :	POSITIVE RESIST)
	COMPOSITION AND METHOD)
	OF FORMING RESIST)
	PATTERN)
)
Examiner :	Unknown)

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
 P.O. Box 1450
 Alexandria, VA 22313-1450

Dear Sir:

Enclosed is form PTO/SB/08 equivalent listing references that are also enclosed. As indicated in the accompanying Form PCT/ISA/210, all documents except Nos. JP 2000-188250 and JP 2000-356850 were cited in the International Search Report in the international phase of the present U.S. national phase application. Although these references already of record during the International Phase of the application, they are submitted in the present Information Disclosure Statement for the convenience of the Examiner and to ensure that the references are listed on the cover of any patent issued on the present application.

The document Nos. JP 2000-188250 and JP 2000-356850 are additional references that are not previously cited during the International Phase. These references are relevant to the drawings as well as the information disclosed in the publications.

This Information Disclosure Statement is being filed within three months of the filing date of this application or upon filing if this is a CPA or RCE, and no fee is required in accordance with 37 C.F.R. § 1.97(b)(1), (b)(2), or (b)(4).

Respectfully submitted,
 KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: June 22, 2005

By: 
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT		Int'l Application No.	PCT/JP03/16266
		Int'l Filing Date	December 18, 2003 10/15/2005
		First Named Inventor	Kazufumi SATO
		Art Unit	Unknown
(Multiple sheets used when necessary)		Examiner	Unknown
SHEET 1 OF 1		Attorney Docket No.	SHIGA7.021APC

U.S. PATENT DOCUMENTS

Examiner Initials	Cite No.	Document Number Number - Kind Code (if known) Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear

FOREIGN PATENT DOCUMENTS

Examiner Initials	Cite No.	Foreign Patent Document Country Code-Number-Kind Code Example: JP 1234567 A1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T ¹
	1.	JP 06-069118	03/11/94	NEC Corp.	(English Abstract Only)	X
	2.	JP 11-119443	04/30/99	Oki Electric Ind Co Ltd	(English Abstract Only)	X
	3.	JP 11-168052	06/22/99	Mitsubishi Electric Corp; Ryoden Semiconductor Syst Eng Corp	(English Abstract Only)	X
	4.	JP 2000-188250	07/04/00	Oki Electric Ind Co Ltd	(English Abstract; Corresponding to 6,368,980 B1)	X
	5.	JP 2000-356850	12/26/00	Samsung Electronics Co Ltd.	(English Abstract; Corresponding to 6,485,895 B1)	X
	6.	JP 2001-274062	10/05/01	Oki Electric Ind Co Ltd	(English Abstract; Corresponding to 6,511,794 B1)	X
	7.	JP 2002-241442	08/28/02	Daicel Chem Ind Ltd	(English Abstract Only)	X
	8.	EP 1 357 284 A1	10/29/03	Toyota Jidosha KK; Nok Corp.	(Corresponding to JP 2003-321520)	
	9.	WO 00/46640	08/10/00	Sumitomo Chem Co Ltd	(English Abstract; Corresponding to 6,627,381 B1 & JP 2000-227658)	X
	10.	WO 01/73512 A1	10/04/01	Sumitomo Chem Co Ltd	(English Abstract; Corresponding to 2003/0113661 A1 & JP 2001-272782)	X
	11.	GB 2 356 258 A	05/16/01	Sumitomo Chem Co Ltd	(Corresponding to JP 2002-006501)	

NON PATENT LITERATURE DOCUMENTS

Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ¹

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Examiner Signature	Date Considered
*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	

T¹ - Place a check mark in this area when an English language Translation is attached.